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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of Stephen Y. Chou

Serial No.: 10/046,594

Filed: 10/29/2001

Improved Release Surfaces, Particularly For Use In Nanoimprint

Lithography

Group Art Unit: 1732

Examiner: TBA

Honorable Commissioner of Patent and Trademarks Washington, D.C. 20231

SIR:

SECOND PRELIMINARY AMENDMENT

Please amend the above-identified application as follows:

IN THE SPECIFICATION

After the Title on p. 1, please amend the section entitled Related Applications to read as follows:

-- This application is a divisional of U.S. Patent Application Serial No. 09/107,006, filed June 30, 1998, which claims priority to U.S. Patent Nos.